

# Optical Emission Spectroscopy, an emerging technology for CCIT

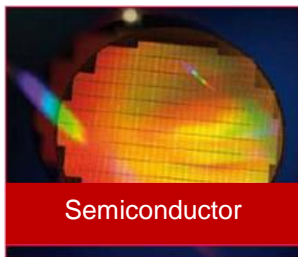
**Instructor:**

- **Philippe BUNOD**, PhD. ; Pfeiffer Vacuum; [philippe.bunod@pfeiffer-vacuum.fr](mailto:philippe.bunod@pfeiffer-vacuum.fr)  
*Business Development Pharma Europe – Integrity Test Solutions*

# Structure

1. Pfeiffer Vacuum at a glance
2. The 3 CCIT technologies proposed by Pfeiffer Vacuum
3. Optical Emission Spectroscopy :
  - How does it work ?
  - Influence and limiting factors
  - Advantages
  - Detection of gross leaks
4. Vacuum test methods / Microbial ingress risk
5. Conclusions

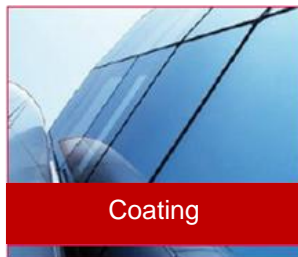
# Pfeiffer Vacuum, leader in vacuum technology



Semiconductor



Industry



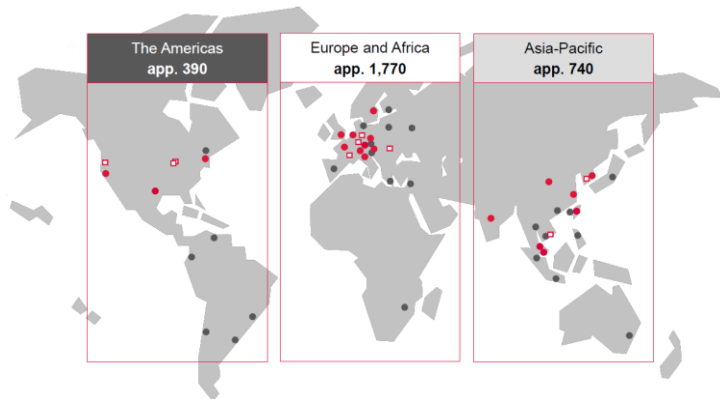
Coating



Analytic



R&D



- **Production**  
Germany: Asslar & Göttingen  
France: Annecy  
South Korea: Asan  
Rumania : Cluj  
USA : Indianapolis & Yreka,  
Vietnam : Ho-Chi-Minh-City

● **Sales and Service**

● **Distributors**

**Total employees**  
**2,945**

# 3 equipments in our CCIT portfolio

## MICRO-FLOW AND MASS EXTRACTION

Micro-flow sensor



**ASTM F3287-17**

## HELIUM MASS SPECTROMETRY

Magnetic deflection spectrometer



**ASTM F2391-05**

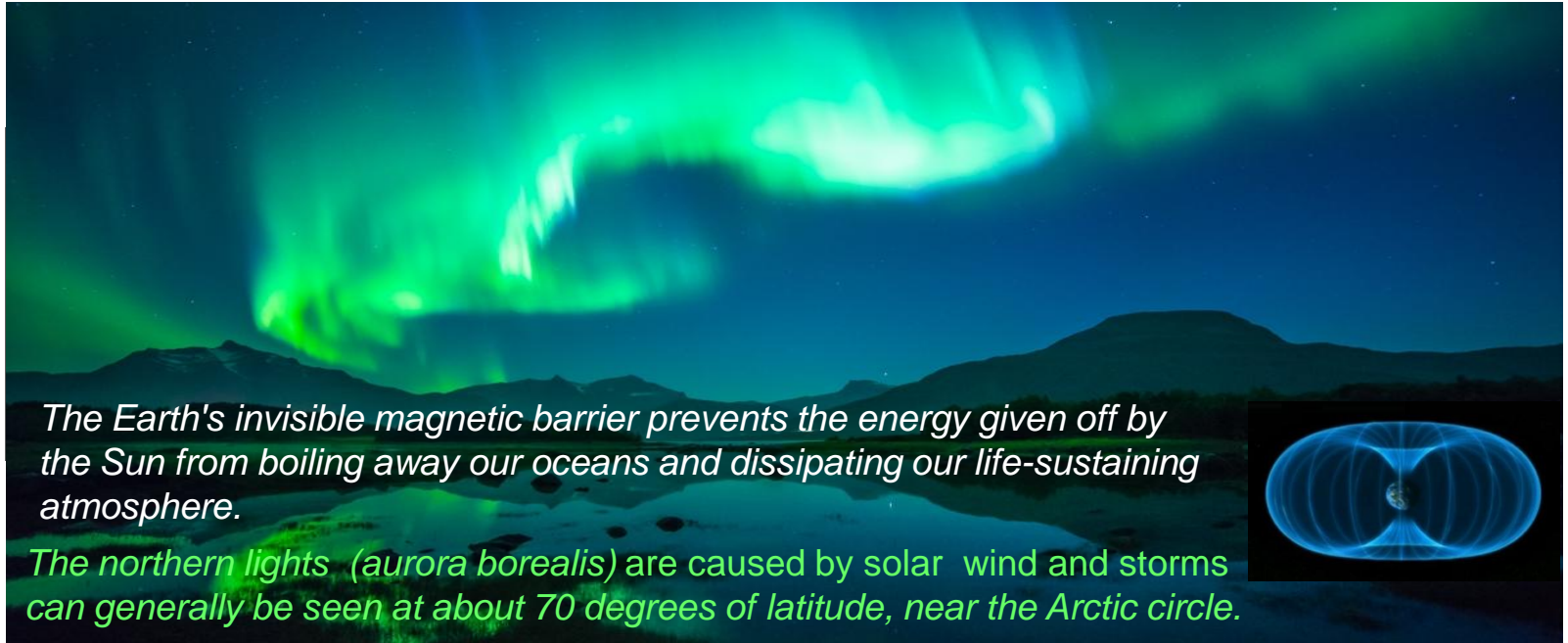
## OPTICAL EMISSION SPECTROMETRY

Multi-gas analyser (N<sub>2</sub>, CO<sub>2</sub>, Ar, H<sub>2</sub>O,..)

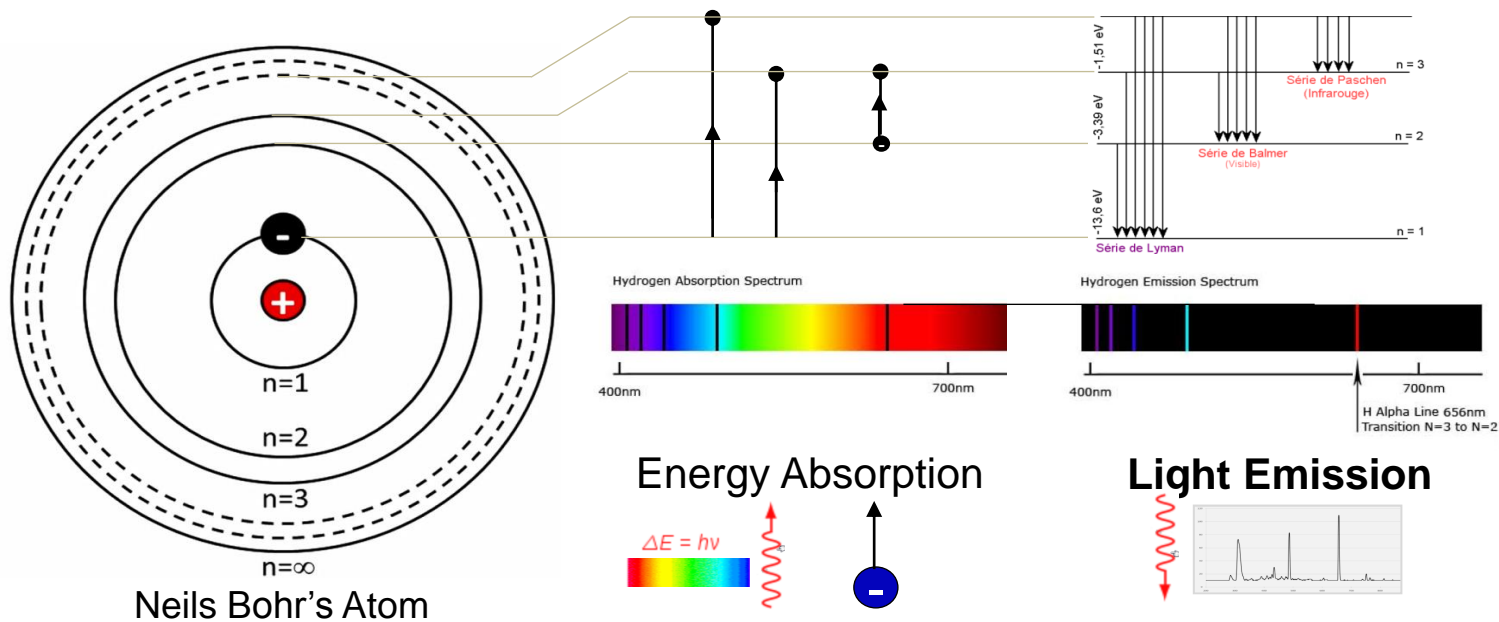


*Emerging Technology*

## O.E.S. – Operating principle



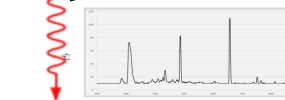
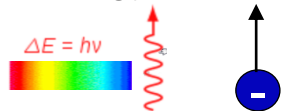
# O.E.S. – Operating principle



Neils Bohr's Atom

Energy Absorption

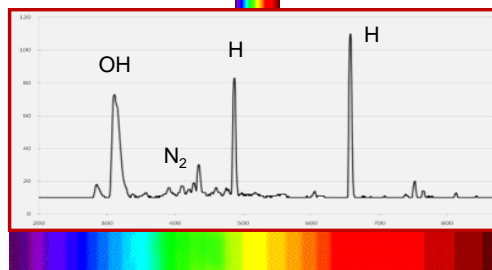
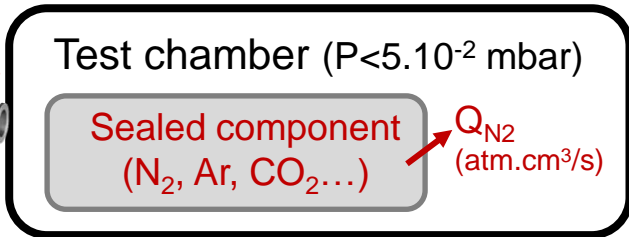
Light Emission



# O.E.S. – Operating principle

A Plasma is the 4<sup>th</sup> fundamental state of matter = hot ionized gas (instable).

Plasma de-excitation give light emission.



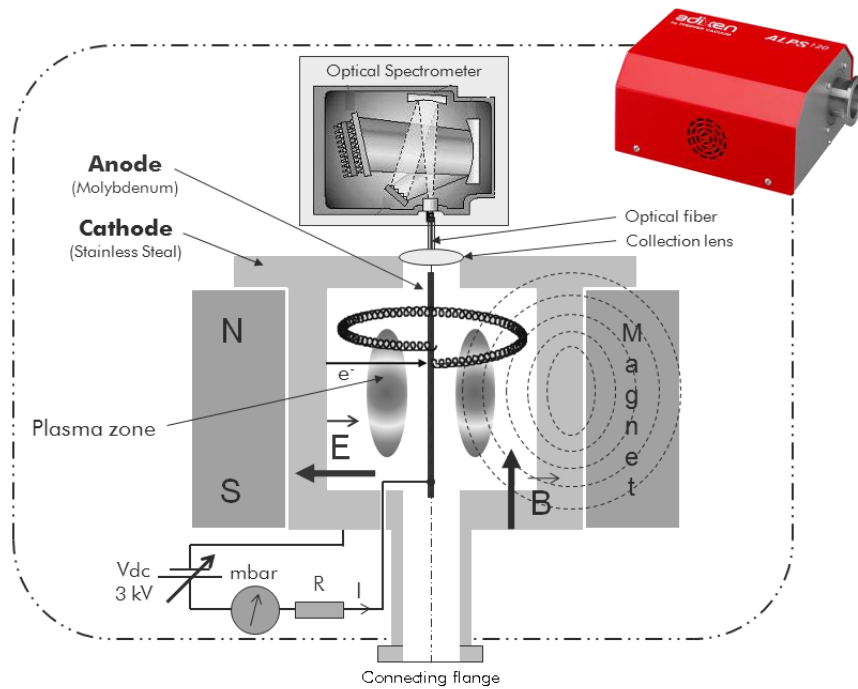
200nm

850nm



To detect leaks we are using our patented multi-gas “ALPS” sensor which is based on O.E.S.

# O.E.S. Sensor Design (Pfeiffer Vacuum patented technology)

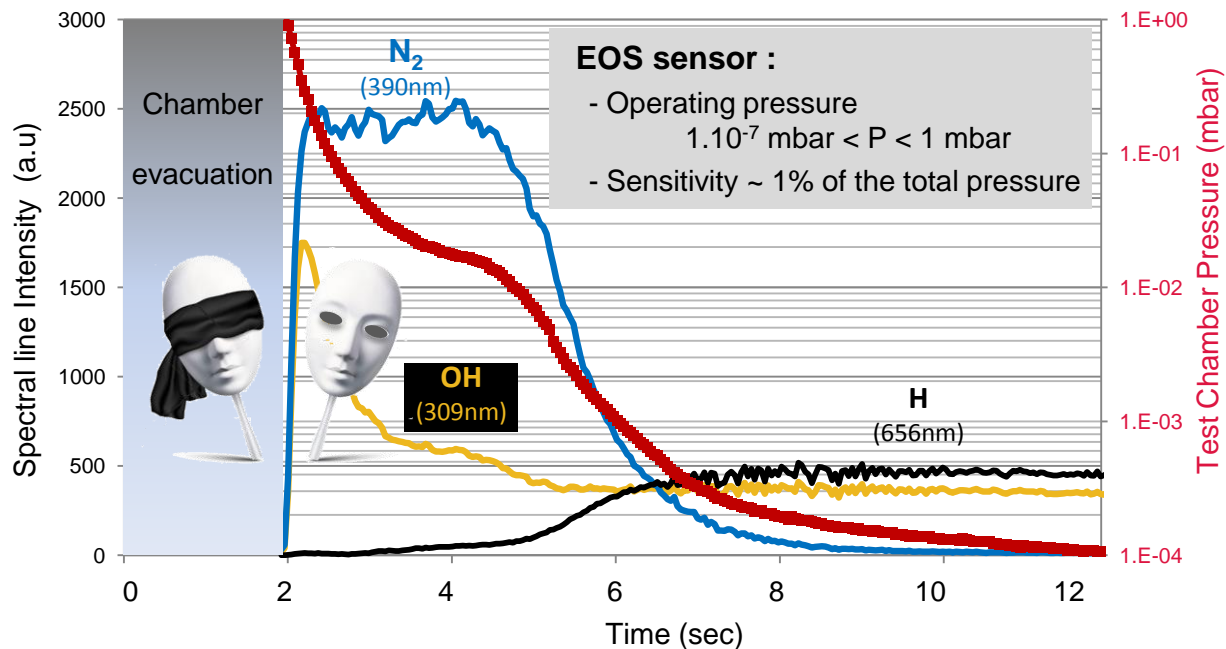


## Cold Cathode Inverted Magnetron design:

- Current (I) is fixed (few  $\mu\text{A}$ )
- High Voltage (Vdc) is adjusted to keep the intensity constant
- The plasma (ionized gas) is generated by electron collisions
- The light is collected by an optical lens and analyzed by an optical spectrometer



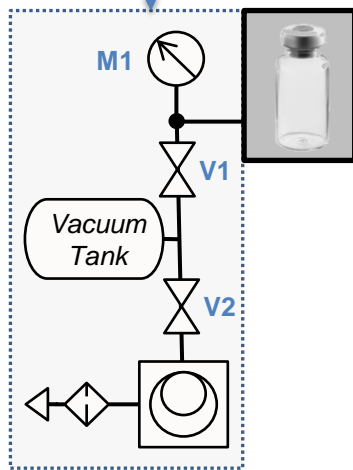
# O.E.S. – Real time measurement



The air (N<sub>2</sub>) inside the test chamber can be easily evacuated using vacuum pumps.

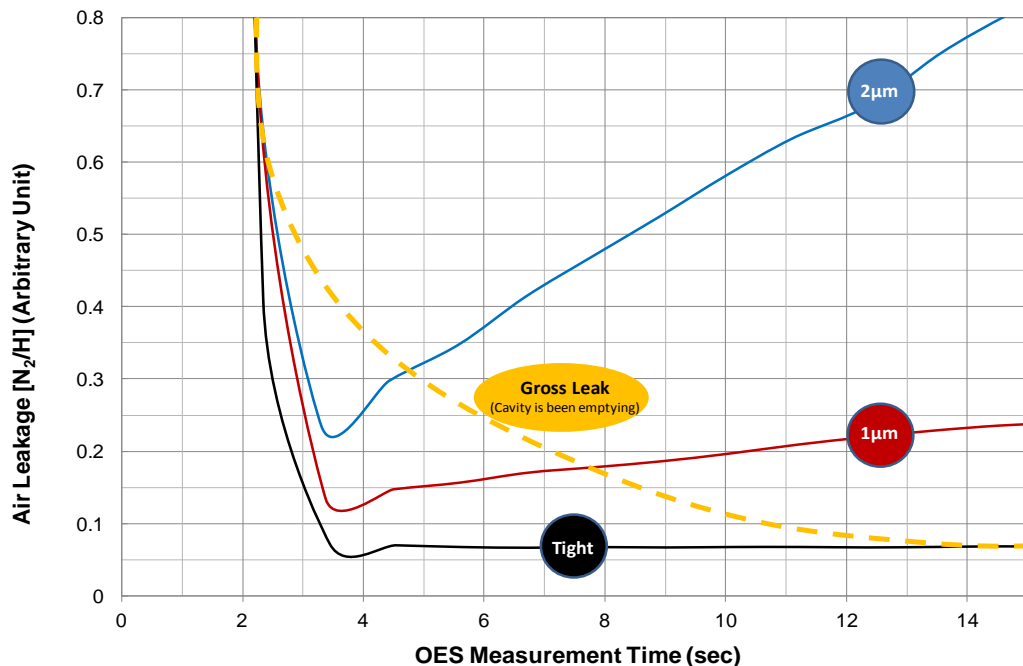
Moisture (H<sub>2</sub>O → H & OH) is much more difficult to evacuate because it is coming from out-gassing of materials in contact with vacuum.

# Massive leak detection prior to OES



- **AMI includes a Massive Leak Detection module (>100µm)**
  - *GO/NOGO test = qualitative measurement.*
- **For Dry Filled Products, based on a volumetric method:**
  - *Pressure equilibrium between a vacuum tank and the test chamber.*
  - *The test chamber is designed in order to minimize the free volume around the sample and the vacuum tank is sized accordingly.*
- **For Liquid Filled Products, based on deep vacuum decay:**
  - *Pressure must be below the vapor pressure of water.*
  - *Free volume around the sample is not anymore an issue.*
- **Massive Leak Detection prevents equipment contamination**
  - *In case of Gross Leak (air/liquid), the high vacuum circuit and OES sensor are not contaminated. Only few components can be easily cleaned and dry.*

# OES – Typical air leakage signal (raw data)

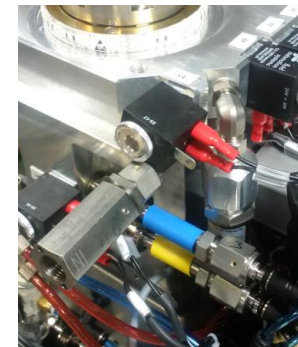
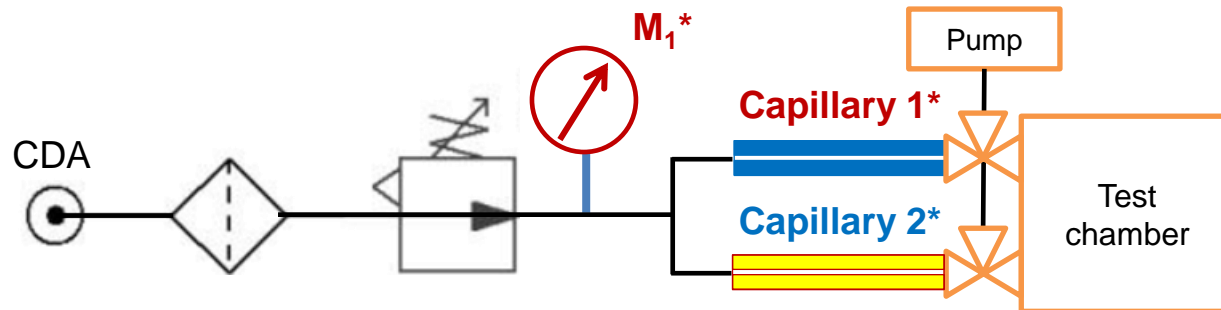


The air leakage corresponds to the intensity ratio  $[N_2/H]$

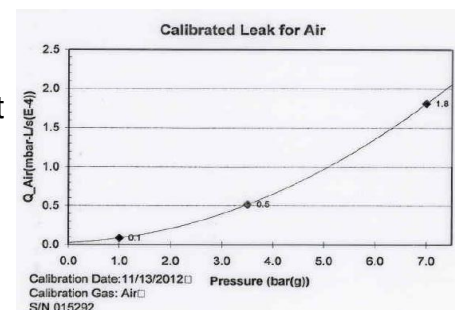
In case of fine leak, the air leakage signal ( $N_2/H$ ) increases as out-gassing (OH & H) is decreasing with time.

In case of gross leak ( $>100\mu\text{m}$  for 1cc headspace), depending on the headspace volume we can see the container being evacuated.

# A set of 2 capillaries is used for calibration



- A set of 2 capillaries allows to generate a calibrated air leak into the test chamber in the range:  $2 \cdot 10^{-5} - 1 \cdot 10^{-3}$  mbar.l/s.
- The air leakage provided by the capillaries depending on the CDA inlet pressure set up by the automatic pressure reducer.
- The M1 gauge measures the exact pressure just among the capillaries
- Calibration certificates are delivered for capillaries & pressure gauge

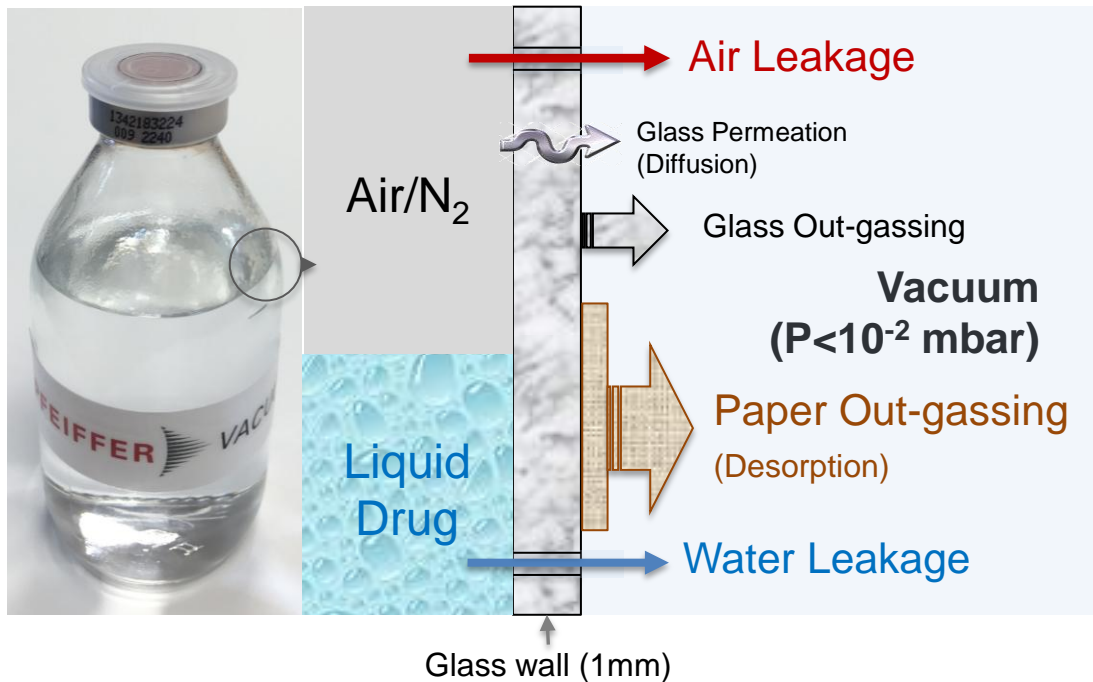


## O.E.S. – Operating sequence

- 1/. Part loading (manually or automatically)
- 2/. Chamber evacuation (1000 → few mbar)  
(Massive Leak detection)
- 3/. Chamber pumping (few mbar →  $<10^{-4}$  mbar)
- 4/. O.E.S. measurement start when pressure is  $< 10^{-2}$  mbar
- 5/. Chamber venting (with Ambient air, dry  $N_2$  or Argon)
- 6/. Part unloading



# Permeation / Out-gassing / Leakage



For all global vacuum test methods, **Permeation** and **Out-gassing** flows correspond to virtual leaks and **limit the sensitivity**.

**Permeation** of air is generally slow and far below the MALL level. **It does not limit the sensitivity**.

**Out-gassing** flow is made of Water (80%) and others gas (20%). It decreases slowly when the time under vacuum increase. **It strongly impacts the sensitivity and/or cycle time**.

# OES – Influence & limiting factors

For all vacuum test solutions:

**Detection limit** ↓ **when Test Duration** ↑

- Out-gassing limit the sensitivity of the test, it can be minimized by:
  - Design of Container and test chamber (material, surface, roughness)
  - Controlling operating conditions: temperature (°C) and humidity (<30%RH)
  - Increasing the test duration... but that increase the risk to miss gross leaks!
- Gross leak detection can be challenging in case of small gas headspace volume combined with a low out-gassing drug.
  - Specific Massive Leak test can be performed prior to O.E.S measurements

# O.E.S. – Measurements are volume independent

Measurement and sensitivity are not impacted by:

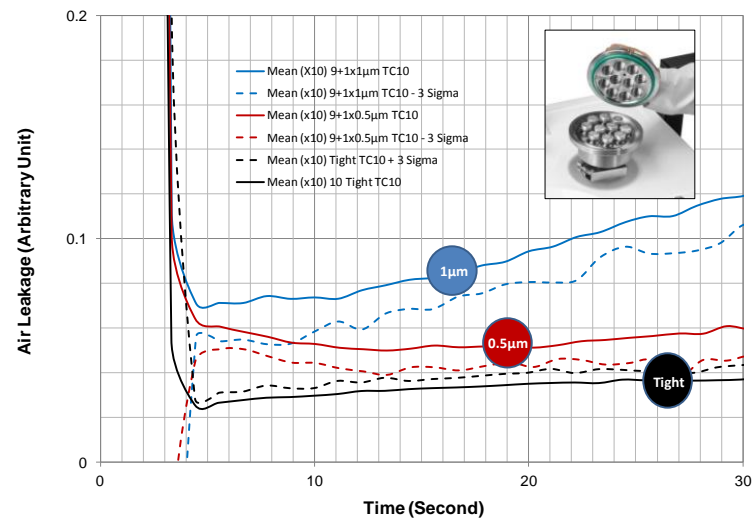
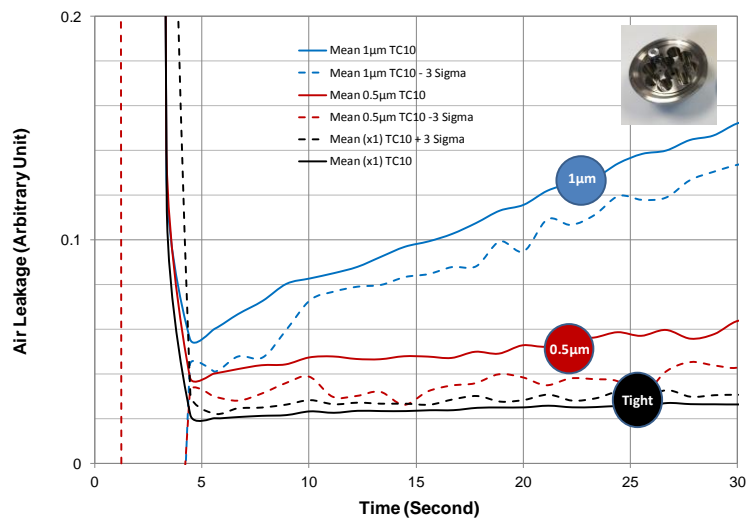
- container expansion during the test  
→ Tests can be performed on semi-rigid containers
- the free space in the chamber around the container  
→ Test of complex design devices (i.e. auto-injectors)  
→ Possibility to test per batch to increase the throughput





# O.E.S. – Method is not volume dependant

→ 0.5 $\mu$ m defect (sharp edge orifice) can be detected in a batch of 10 vials and/or on 1 vial in the same test chamber.



# O.E.S. – Selectivity

## OES multi-gas sensor:

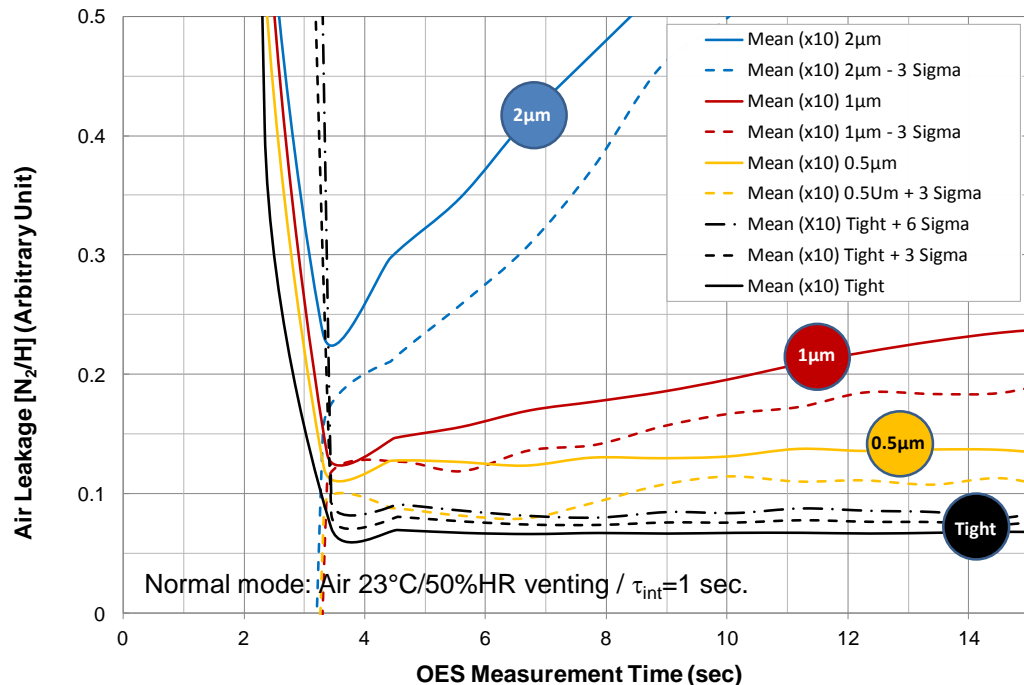
- different gases ( $N_2$ ,  $H_2O$ , Ar,  $CO_2$ ...) can be detected simultaneously  
→ detection limit depends on the gas which is tracked for leak detection
- no interference with out-gassing,  
→ Air /  $N_2$  is tracked independently of moisture (out-gassing)  
→ Air /  $N_2$  is tracked independently of Argon used for chamber venting
- Air/ $N_2$  leak and water leak can be detected simultaneously

# AMI 1000, Unique Selling Proposition

- **High sensitivity & high throughput**
  - 10 sec to detect orifice < 0.4µm on glass vial
  - No impact of the test volume on the sensitivity (test per batch possible, up to 10, 50, 100)
- **Selectivity**
  - Air & water leaks can be measured/detected simultaneous
  - Possible selection of the tracer gas (N<sub>2</sub>, CO<sub>2</sub>, Ar, H<sub>2</sub>O,...)
- **Versatile and easy to use**
  - Applicable for various kind of non-porous packaging's
  - No sample preparation



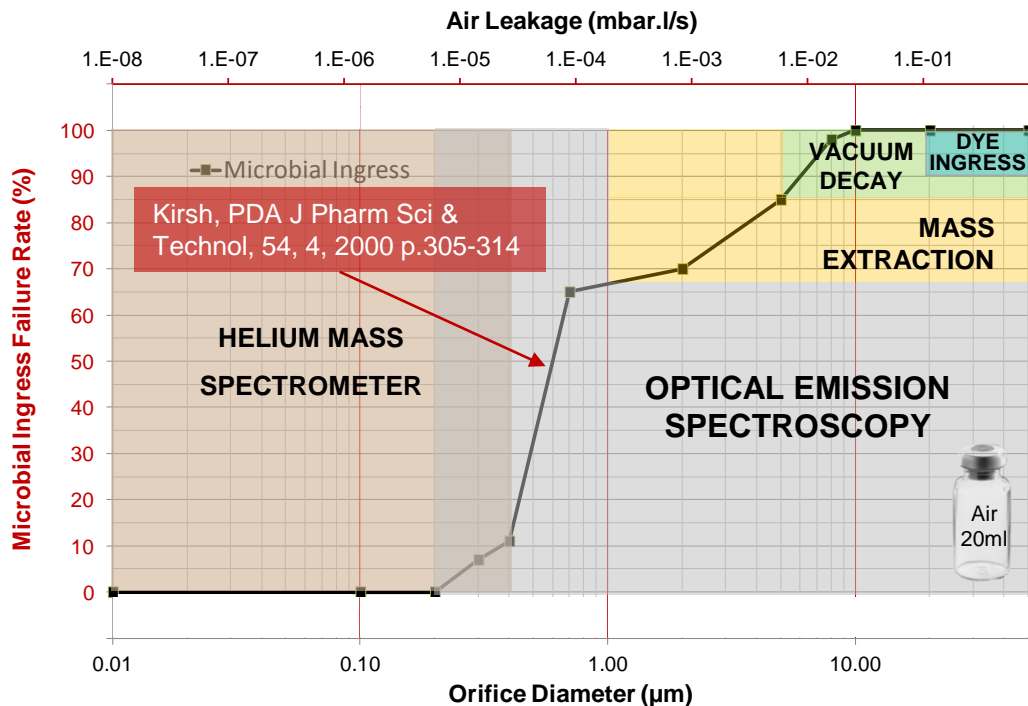
# O.E.S. - Fast and sensitive



The Air Leakage raw signal corresponds to the intensity ratio  $[N_2/H]$ .

OES (Ambiant air venting) 23°C / 50% RH		
Detection Limit	Total Test Duration	
	Leak-3σ Blank+3σ	Leak-3σ Blank+6σ
2 µm	10 sec	10 sec
1 µm	10 sec	10 sec
0,5µm	10 sec	14 sec

# Vacuum Test Methods/Microbial Ingress Risk



Correlation established by Kirsh & all, has been performed on glass vials using glass µ-pipettes artifacts.

The microbial ingress conditions used for this study corresponds to a **worst case**:

Figure 2 – The correlation of microbial failure rate (%) and the mean logarithm of the absolute leak rate and nominal leak diameter for modified SVPs. The absolute leak rate (standard cubic centimeter per second) was determined by mass-spectrometry based helium leak rate detection. Microbial failure was measured by microbial ingress after 24 hour immersion in a bath (37°C) containing  $10^8$  to  $10^{10}$  *P. diminuta* and *E. coli* organisms/ml and a 13 day, 35°C incubation

# Conclusions

O.E.S. technology offers many advantages:

- **Non-destructive** and **deterministic**
- **Easy to operate** and **easy to set-up** (non sample preparation)
- **Versatile** (no format parts required)
- **Selective** (Air/N<sub>2</sub>, Ar, CO<sub>2</sub>, and water leaks can be detected simultaneously)
- **Volume independent** (test of complex product or test per batch)
- **High sensitivity** combined with **high throughput**  
(i.e.: 0.4µm orifice detected within 7 seconds on 20ml glass vials)
- In high sensitivity mode **0.2µm orifice can be detected**

# Conclusions

- AMI equipments, using O.E.S. spectroscopy have been qualified as IPC test for the production of blister packs (high sensitive inhalation drugs).
- Promising technology to perform high sensitivity 100% in-line leak testing.
  - *0.4 $\mu$ m defect (sharp edge orifice) can be detected in 10 sec on glass vial tested one by one or by batch of up to 10.*

# Thank you for your attention !

Links <http://www.pfeiffer-vacuum.com>  
Email : [philippe.bunod@pfeiffer-vacuum.fr](mailto:philippe.bunod@pfeiffer-vacuum.fr)

